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CCS H 10

SN

**INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

SN/T 2259-2009

**Determination of chemical components in high purity copper
cathode. Inductively coupled plasma atomic emission
spectrometry**

高纯阴极铜中化学成分的测定 电感耦合等离子体原子发射光谱法

(English Translation)

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What this standard covers

This standard specifies the inductively coupled plasma atomic emission spectrometry (hereinafter referred to as ICP-AES) determination of the chemical composition of high purity copper cathode method. This standard applies to high purity copper cathode in silver, arsenic, bismuth, cadmium, cobalt, chromium, iron, manganese, nickel, phosphorus, lead, antimony, selenium, silicon, tin, tellurium, zinc determination. Measuring range: see Table 1.

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Standards quoted by this document

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